Review of RF photoinjector for radiation chemistry

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Application for ultra-short pulse

-Radiation Chemistry experiments

Purpose of the sub-ps pulse radiolysis

 Investigation of the elementary process of radiation induced phenomena which occur in the time scale of ps, even sub-ps



Application for ultra-short pulse — Radiation Chemistry experiments

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Radiation Chemistry

Pulse radiolysis method

Chemical reaction of water



Time

Requirements

- Pulse radiolysis in a time range of sub-picosecond
- I Ultra-short bunch and laser
- II Stable synchronization
- III Intense electron bunch

For Pumping beam

Short pulse Single beam, low dark current High intensity For Probe beam

Short pulse Synchronization to pumping beam Tunable wavelength

fs laser(Ti:Sapphire laser)

+

Photocathode RF gun

Suitable combination





Preliminary Pulse Radiolysis; 795 nm

Beam-Material Intera www.utns.jp/~beam

Condition

	H ₂ O&1M H⁺	H ₂ O			
//mm	20 mm	5 mm			
Charge	0.8-1.0nC	0.8-1.0nC			
Beam size	4mm	4mm			
Pulse width	7ps	3ps			
Wavelength	795nm				
Average	64	16			
Time resol.	30ps	9ps			



Results

- O.D. still low



Pulse radiolysis using white light continuum

Beam-Material Interactions www.utns.jp/~beam



Comparison with conventional linac

	Convent	ional linac	Photocathode			
	Long-pulse mode Single-pulse mode		In 2000	Current		
Charge	8~20nC	0.5~0.6nC	0.8~1.0nC	1.7~2.0nC		
Beam size	15x6mm	4mm	4mm	3mm		
Dose/shot	30~50Gy	7~8Gy	13~15Gy	>40Gy		
Pulse width	10-100ns	10ps	7ps	3ps		





- (4) 10ps /10mm : Δt_{EB-L} in $H_2O \rightarrow$ Thinner cell, but $OD \downarrow \rightarrow$ High-Brightness EB

Femtosecond electron beam and femtosecond pump-probe experiment in Osaka University



Osaka Univ.

A new concept of "equivalent velocity spectroscopy" for studies of ultrafast electron-induced reactions





Temporal distribution of 98 fs electron bunch measured by the streak camera at 0.17 nC



Transient absorption kinetics of hydrated electrons measured in water at wavelength of 800 nm



LEAF





- 1) Diode-pumped Nd:YVO ____ laser, 5 Watts, 532 nm, pumps picosecond Ti:Sapphire laser.
- 2) Ti:Sapphire oscillator produces ~50 fs pulses, ~ 7 nJ energy, 798 nm, at 81.60 MHz.
- Pulse stretcher stretches oscillator pulse to > 200 ps, then injects the pulse into the Ti:Sapphire regenerative amplifier.
- 4) Simultaneously, the doubled, Q-switched Nd-YAG laser pumps the Ti:Sapphire regen.
- 5) Stretched ~200 ps pulse is amplified to ~12 mJ level. Half is compressed to 1-3 ps for THG
- 6) 1-3 ps pulse is frequency tripled to 266 nm (\leq 0.4 mJ) for excitation of Mg photocathode.
- 7) Half of regen output compressed to ~100 fs for use as probe or TOPAS OPA pump (8)



Pulse-Probe Experiment



LEAFPulse-probe transient absorptionLEAFspectroscopy

Time resolution \geq 7 ps

A factor of pulse width and sample depth.

Optical Parametric Amplifier (240 - 2600 nm)

New diodes extend range from 1000 to 1700 nm

Color separation needs work, far-field mode varies

Better Signal/Noise than before

Improved LabVIEW acquisition software

Interleaved collection, measurement selection criteria (dose, laser intensity, modulator and laser timing), using consistent cathode recovery time

More proficient laser and electron beam alignment

Igor-based analysis software

Flow system volumes reduced (~4 ml or \geq 15 ml)

ELYSE,Orsay



ELYSE, Picosecond Pulse Radiolysis

ELYSE,Orsay

Photoinjector Accelerator

- Pulse length $\leq 7 \text{ ps}$
- ♣ Charge $\ge 1 \text{ nC}$
- ♣ Energy 4 to 9 MeV
- ♣ Repetition Rate ≤ 50 Hz
- ♣ Energie Dispersion ≤ 2,5 %
- ♣ Spot Diameter ≤ 2 à 20 mm
- Pulse-Probe

Accelerator build and installed (SERA)



Waseda Univ. (Japan)



New pulseradiolysis system



Waseda Univ. (Japan)



NA

NA



	Beam energy	Beam Current	Beam width	Beam size	Target path Length	Synchro- nization	Laser pulse width	Total time Resolution
U. Tokyo	4+18= 22MeV	2nC	1ps	3mm	1mm	<1ps(rm s)	100fs(532nm- 2600nm)OPA (400-1100nm) white light made by Ti:Sa	3ps(white light)
LEAF,BNL, USA	9MeV	2-8nC	≥ 7 ps		10mm(ri ght water)	Pico-sec.	100fs(240- 2600nm)OP A	>7ps(pulse -probe)
ELYSE, France	4 to 9 MeV	≥ 1 nC	≤ 7 ps	2-20mm				~7ps?
Waseda Univ.	4MeV	0.4- 0.6nC						8ps
Osaka Univ.	38MeV	>0.2nC	<1ps				100fs	~5ps

Summary

Photocathode RF gun with fs laser(Tt:Sa) is suitable combination for the Application of Radiation Chemistry

In order to measure the phenomena at sub-pico or picosecond region, we need;

- -high brightness beam with short pulse(<1ps)
- -Thin target(~mm)
- -Stable system Timing (within 1ps) Position Beam Intensity (both laser and electron beam)

Special thanks to LEAF, BNL ELYSE, Orsay Univ. Osaka Waseda Univ. Univ. Tokyo

- Factor of the thermalization distance $\lambda_m = (n\sigma)^{-1}$ $\lambda = [-\lambda_m \ln (P \lambda_m)]/\alpha$
- Factor of the cross section of geminate ion recombination $\sigma_{rec} \sim 3 \ge 10^{-20} E^{-1.86} \ge \beta$
- Branching ratios in physicochemical stage stems from ionization and excitation

	•	Probability		Probability	Reaction No.		
Decay of the directly excited water molecules							
$H_2O^*(A^1B_1)$	\rightarrow H ₂ O	P1			(1)		
	\rightarrow H + OH	P2					
$\mathrm{H}_{2}\mathrm{O}^{*}(B^{1}A_{1})$	\rightarrow H ₂ O ⁺ + e ⁻	P6			(4)		
	\rightarrow H ₂ O	(1-P6)P1			(1)		
	\rightarrow dissociation	(1-P6)P2	→ H + OH	Р3	(2-1)		
			\rightarrow 2H + O(3P)	P4	(2-2)		
			\rightarrow H ₂ + O(¹ D)	P5	(2-3)		
Decay of the excited states results from the recombination							
H_2O*	\rightarrow H ₂ O	P1			(1)		
	\rightarrow dissociation	P2	→ H + OH	P7	(3-1)		
			\rightarrow 2H + O(3P)	P8	(3-2)		
			\rightarrow H ₂ + O(¹ D)	Р9	(3-3)		

Ultra-fast pump-and-probe pulse radiolysis study : radiation induced fast processes



Time behaviors of hydrated electrons in water: Solvation time < time resolution < 10ps

Time behaviors of solvated electrons in ethanol: Observation of solvation process ($e_{pre}^{-} \rightarrow e_{sol}^{-}$)



Sub-ps Pulse Radiolysis - Measurement System **Beam-Material Interactions, UTNs** TK SI5010 **GPIB** Computer **SR DG535** Laser HP 37204A Computer HP 54845A Stage driver Shutters PD 1 **PD 2** Electron 18MeV linac Current beam Sample or monitor 🔶 Light 35MeV linac **FESCA** ➡ Signal **Data acquisition** • Measurement of laser intensity and charge Calculation of precise absorbance - **B** : Both beam and light $\rightarrow I_{M}(B)$ and $I_{R}(B)$ Absorbance = $\log_{10} \frac{I_0}{I} = \frac{C_{ave}}{C} \cdot \log_{10} \left[\frac{I_M(L) - I_M(N)}{I_R(L) - I_R(N)} \cdot \frac{I_R(B) - I_R(P)}{I_M(B) - I_M(P)} \right]$ $\rightarrow I_M(L) \text{ and } I_R(L)$ $\rightarrow I_M(P) \text{ and } I_R(P)$ - L : Light only - **P** : Beam only $\rightarrow I_{M}(P)$ and $I_{R}(P)$ - N : Neither beam nor light $\rightarrow I_M(N)$ and $I_R(N)$ $(C_{ave}: \text{Average of charges})$ - Charge $\rightarrow C$

 $(I_M: Main light, I_R: Reference light)$